Strain-Induced Coupling of Spin Current to Nanom echanical Oscillations

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We propose a setup which allows to couple the electron spin degree of freedom to the mechanical motions of a nanomechanical system not involving any of the ferrom agnetic components. The proposed method employs the strain-induced spin-orbit interaction of electrons in narrow gap semiconductors. We have shown how this method can be used for detection and manipulation of the spin ow through a suspended rod in a nanomechanical device.

PACS numbers: 71.70 Ej, 71.70 Fk, 72.25.-b, 75.40 Gb

An ability to control the spin transport in semiconductors is a key problem to be solved towards in plementation of semiconductor spintronics into quantum information processing [1, 2, 3]. Many methods have been proposed to achieve control of the electron spin degree of freedom using magnetic materials, external magnetic elds and optical excitation (for a review see Ref. [3]). O ther promising ideas involve the intrinsic spin-orbit interaction (SO I) in narrow gap semiconductors to manipulate the spin by means of electric elds [4] and electric gates [5, 6, 7]. Recently, some of these ideas have been experimentally con med [8, 9].

In semiconductors the spin-orbit e ect appears as an interaction of the electron spin with an e ective magnetic eld whose direction and magnitude depend on the electron m om entum. A specic form of this dependence is determ ined by the crystal sym metry, as well as by the symmetry of the potential energy prole in heterostructures. In strained sem iconductors new components of the e ective magnetic eld appear due to violation of the local crystal sym metry [10]. The e ect of the straininduced SO I on spin transport was spectacularly demonstrated by K ato et. al. in their Faraday rotation experim ent [9]. An interesting property of the strain-induced SO I is that the strain can be associated with mechanical motion of the solid, in particular, with oscillations in nanom echanical systems (NMS), in such a way making possible the spin-orbit coupling of the electron spin to nanom echanical oscillations. At the same time a big progress in fabricating various NMS [11] allows one to reach the required param eter range to observe subtle effects produced by such a coupling.

In this Letter we will consider NMS in the form of a suspended beam with a doped semiconductor Im epitaxially grown on its surface (see Fig. 1). An analysis of the SOI in this system shows that the exural and torsion vibrational modes couple most e ciently to the electron spin. As a simple example, we will focus on the torsion mode. The strain associated with torsion produces the spin-orbit eld which is linear with respect to the electron momentum and is directed perpendicular to

it. This eld varies in time and space according to respective variations of the torsion strain. Due to the linear dependence on the momentum, the SO I looks precisely as interaction with the spin dependent electrom agnetic vectorpotential. An immediate result of this analogy is that the time-dependent torsion gives rise to a motive force on electrons. Such a force, however, acts in di erent directions on particles with oppositely oriented spins, inducing thus the spin current in the electron gas. The physics of this phenom enon is very similar to the spin current generation under tim e-dependent Rashba SO I, where the tim e dependence of the SO I coupling parameter is provided by the gate voltage variations [6]. In the present work we will focus, however, on the inverse e ect. Due to the SO I coupling, the spin current owing through the beam is expected to create a mechanical torsion. The torque e ect on NMS due to spin ow has been previously predicted by M ohanty et. al. [12] for a di erent physical

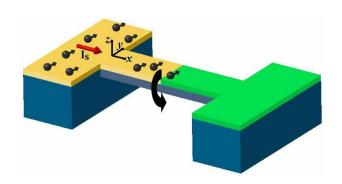


FIG. 1: Schem atic illustration of electrom echanical spin current detector, containing a suspended sem iconductor-metal (S-M) rectangular rod atop an insulating substrate (blue). A spin current is injected from the left sem iconductor reservoir (yellow) and then disuses toward the metallic lm (green). While passing through the sem iconductor lm, the spin current induces torque shown by the black arrow.

realization, where the torque has been created by spin ips at the nonmagnetic-ferromagnetic interface. They also suggested an experimental setup to measure such a small torque. As it will be shown below, the torque due to the strain induced SOI can be large enough to be measured using the experimental setup proposed in Ref. [12]. Besides this method, other sensitive techniques for displacement measurements can be employed [13].

The system under consideration is a rectangular beam of the total length $L_{\rm t}$, width b, and thickness c. The coordinate axes are chosen as shown in Fig.1. The sem iconductor lm with the thickness c=2 occupies the length L of the beam. The rest part contains a metal lm. It can also include some additional elements for detection of the torque, for example in Ref. [12]. Here we will consider an example when the spin current is created by di usion of the spin polarization from the left contact in Fig.1. Therefore, there is no electric current ow through NM S. The spin polarization di uses towards the metal lm which, due to its relatively high conduction, can play an important role as a reservoir for the spin polarization relaxation.

W e start from the strain-induced SO I [10] described by the H am iltonian

where u_{ij} are elements of the strain tensor, $_i$ stand for Paulim atrices and k_i denote components of the electron wave vector. In the narrow gap semiconductors the parameter is usually much smaller than [10]. Therefore, the term proportional to will be omitted below. Besides the strain-induced H $_{\rm SO\,1}$, the total SO I H amiltonian also includes the strain independent interaction H $_{\rm SO\,2}$. Because of submicron cross-section dimensions of the doped semiconductor lm , H $_{\rm SO\,2}$ will be determined by the bulk D resselhaus term [15].

$$H_{SO2} = \int_{ijn}^{ijn} jk_i (k_j^2 - k_h^2)$$
 (2)

This interaction, in the range of doping concentrations 10^{17} cm 3 and higher, provides the main mechanism for spin relaxation in bulk materials [10].

Since the S-M rod with total length $L_{\rm t}$ b and c, the major contribution to the strain comes from exural and torsion motions of the rod [14]. Within the isotropic elastic model the exural motions are represented by the diagonal elements $u_{\rm xx}$ and $u_{\rm yy}$ [14] which do not enter into the rst square brackets of Eq. (1). On the other hand, due to the crystal anisotropy elects, the $u_{\rm xy}$ components are not zero for such sort of motion and could contribute to Eq. (1). We will consider, however, the simplest example of torsion motions of the rod within an

isotropic elastic model. In this case the strain can be represented as [14]

$$u_{yx} = \langle x \rangle \frac{\theta}{\theta z}; u_{zx} = \langle x \rangle \frac{\theta}{\theta y}; u_{yz} = 0;$$
 (3)

where (x) = 0 = 0x stands for the rate of torsion determined by the torsion angle . The function depends only on z and y and is uniquely determined by the rod cross-section geometry.

The next step is to derive from the one-particle interaction Eq. (1) a Ham iltonian which describes a coupling of the spin current to the strain. The electron system carrying the spin current can be described by a density matrix ^. In the fram ework of the perturbation theory the leading correction to the electron energy due to the SO I induced strain can be obtained by averaging H SO I with ^. In the sem iclassical approximation such a procedure can be represented as averaging over the classical phase space with the Boltzmann distribution function \hat{F}_k (r). This function is a 2 2 m atrix in the spinor space. One can also de ne the spin distribution function $P_k^i(r) = (1-2)Tr[\hat{F_k}(r)^i]$. It is normalized in such a way that the local spin polarization $P^{i}(r) = {}^{i}_{k} P_{k}(r)$ W e notice that, due to electron con nem ent in y and z directions, the averages of H $_{\rm SO\,1}$ containing $k_{\rm v}$ and $k_{\rm z}$ turn to zero. A ssum ing that electron distribution is uniform within the cross-section of the semiconductor im one thus obtains, from Eqs. (1) and (3), the SO I energy

$$E_{SO} = 2 \int_{0}^{Z} dx \frac{\theta}{\theta x}$$

$$X Z$$

$$k_{x} dydz P_{k}^{y}(x) \frac{\theta}{\theta z} + P_{k}^{z}(x) \frac{\theta}{\theta y} : (4)$$

This expression can be further simplified taking into account that turns to zero on a free surface [14]. Hence, in the example under consideration = 0 on the top and side surfaces of the doped semiconductor lm. Consequently, the second term in Eq. (4) vanishes after integration over y. Now Eq. (4) can be expressed in terms of the spin current J^y (x) which is the ux in x-direction of y-polarized spins.

$$J^{Y}(x) = S \qquad V_{x}P_{k}^{Y}(x); \qquad (5)$$

where S = bc=2 is the sem iconductor lm cross-section and v_x is the electron velocity in x-direction [16]. Finally, Eq. (4) can be transformed to

$$E_{SO} = \int_{0}^{Z_{L}} dx J^{y}(x) \frac{\theta}{\theta x} :$$
 (6)

Here the coupling constant is given by

$$= {\begin{array}{*{20}{c}} Z & \frac{b}{2} \\ 0 & \frac{b}{2} \\ \end{array}} (y; z = 0) dy; \tag{7}$$

where $_0 = 2m = hS$.

From the last equation, it is seen that the spin-polarized ow imposes a distributed torque on the rod. In order to study this e ect in detailwewillneglect, for simplicity, the dierence between elastic constants of semi-conductor and metalparts of NMS. As such, the equation of motion for the torsion angle can be then written as

$$I\frac{\theta^2}{\theta t^2} \qquad K\frac{\theta^2}{\theta x^2} \qquad \frac{\theta}{\theta x} [J^y \quad (L \quad x)] = 0; \qquad (8)$$

where (x) denotes the Heaviside function, K stands for the torsion rigidity, and I is the moment of inertia. It is easy to gure out that the torque imposed by the SO I on NMS can be expressed as

$$T = \frac{Z_{L}}{L_{0}} dx J^{Y}(x) \qquad J^{Y}; \qquad (9)$$

and, for the S-M $\,$ rod clamped on both ends, the torsion angle at x = $\,$ L $\,$

$$_{L} = \frac{L (L_{t} L)T}{L_{t}}; \qquad (10)$$

where L_t is the total length of the rod. From Eq. (8) one can easily see that if the sem iconductor Im covers the entire length of the beam $(L=L_t)$ and the spin current is hom ogeneous along it, the last term in Eq. (8) turns to 0. Consequently, for a doubly clamped beam the solution of Eq. (8) is (x) 0. In this case, in order to obtain the nite torsion angle, the NMS must include Im s w ith dierent spin-orbit coupling parameters Im s w in Fig. 1 where Im s w w in the metal Im s w w in the other hand, if Im s w depends on Im s w in the example considered below, the metal Im s w is not so necessary. In this example it is shown, however, that such Im s w in can be useful as a reservoir for fast spin relaxation, enhancing thus the di usive spin current ow through the beam .

In order to evaluate the torque, let us adopt the following simple model, which is also convenient for an experimental realization. Namely, we assume that the spin current is due to spin di usion from the left contact. The spin polarization $P^{y}(0)$ can be created there by various methods ranging from absorption of circularly polarized light to injection from a ferromagnet β]. One more possibility is the electric spin orientation β]. For the steady state the di usion equation reads

$$D_{i} \frac{d^{2}P^{y}}{dx^{2}} \frac{P^{y}}{i} = 0;$$
 (11)

where D $_{\rm i}$ and $_{\rm i}$ are di usion coe cients and spin relaxation times, with the subscript i indicating the physical quantities in semiconductor (0 < x < L) ($\not\equiv$ S) or metal (x > L) ($\not\equiv$ M) regions. At the semiconductor-metal interface the di usion current and magnetization P $^{\rm y}$ =N $_{\rm i}$ (0) must be continuous, where N $_{\rm i}$ (0) is the semiconductor or

m etal density of states at the Ferm i energy [17]. We will assume that the length of the metal part of the rod is larger than the spin di usion length $l_{\rm M}=\frac{{\rm P}}{{\rm D}_{\rm M}}\frac{{\rm P}}{{\rm M}_{\rm M}}$. Therefore, the spin current passes through the sem iconductor lm and further decays within them etal lm . Obviously, in the considered example there is no charge current through the system . Solving the di usion equation for $l_{\rm S}$ L and ($_{\rm M}$ L)=($_{\rm S}$ $l_{\rm M}$) 1, where $_{\rm M}$ and $_{\rm S}$ are the 3D conductivities of metal and sem iconductor, respectively, we obtain

$$J^{Y} = \frac{D_{S}P^{Y}(0)S}{I_{I}}:$$
 (12)

Since the ratio $_{M}$ = $_{S}$ is very big, Eq. (12) is valid in a broad range of not very small L.

For a num erical evaluation of the spin-orbit torsion effect we take b = 400 nm and c = 200 nm. The SOI coupling constant = h = 4 10^5 m/sec in GaAs [18]. From Eq. (7) and Ref. [14], it is easily to obtain the spincurrent{torsion coupling parameter = $_0k_2b^3$, where k_2 is a num erical factor depending on the ratio c=b. At b=c=2 the factor $k_2=0.03$. For such num erical param eters we nd = 2.4 10 32 J sec. It is interesting to compare the torsion e ect from the strain induced SOI with that produced by spin ips at the FM-NM interface [12]. In the latter case $T = hI_s$, where I_s is of the order of the spin current in jected at the FM -NM contact when the electric current passes through it. Comparing this expression with Eq. (9), it is seen that at the same spin currents the SOIe ect is much stronger, by the factor = h' 2:2 10°. On the other hand, in [12] the FM -NM contact can be fabricated from all metallic components, while our device must contain the narrow gap sem iconductor lm. In the form er case NMS is able to carry much larger spin current, due to the weaker, by S = M, Joule heating e ect. However, the m easurem ent setup suggested by M ohanty et. al [12] allows to measure torsion e ects produced by quite weak currents. For example, at $eJ^y = 10^{-8} Amp$ the torque 10²¹ N m, which is within the sensitivity T = 1:5claim ed in [12]. Moreover, the measurement sensitivity can be enhanced [19]. Within our model we can evaluate the spin polarization P^{y} (0) which can produce a measurable e ect on NM S. From Eq. (12), taking L = 2 m, the typical low tem perature di usion constant 300 cm²/sec and $n = 10^{17}$ cm³, one obtains $eJ^{y} = 10^{4} (P^{y} (0)=n) nA$. Hence, a measurable 10 nA spin current in NMS can be created by di usion of spin polarization from an adjacent reservoir containing only 0:1% of spin-polarized carriers. Various methods [3, 8, 9] are able to provide such and even much larger spin polarization. Higher spin currents are, however, restricted by the heating e ects, which depend on the practical design of NMS.

It should be noted that the torsion measurement method of Ref. [12] applies to a time-dependent torque in resonance with a NMS oscillation. For such a mea-

surement the spin current could be modulated in time by a narrow gate between the left contact and the rod, or by varying the spin polarization in the left reservoir, for example, if it is created by absorption of circularly polarized light with modulated intensity.

The static torsion angle at x=L can be found from Eq. (10). On the other hand, the maximum torsion effect is obtained for the time-dependent spin current in resonance with the NMS fundamental oscillation. In this case, the torsion angle $_L$ in Eq. (10) must be multiplied by Q=2, where Q is the resonance quality factor, which can be quite large in NMS. To observe this torsion angle it must be much larger than the mean amplitude of its thermal uctuations $\frac{1}{2}$. For a doubly clamped rod

$$_{L}^{2} = \frac{k_{B} T L_{t}}{{}^{2}K} \frac{X}{n^{2}} \frac{1}{n^{2}} \sin^{2} \frac{nL}{L_{t}} : \qquad (13)$$

For a rectangular cross-section with b=c = 2, the torsion rigidity K = 0.057 b³c [14], where '3:3 10^{10} N =m² in G aA s m aterial. Taking L_t = 5 m and all other param eters the same as in the previous paragraph, Q = 10^4 and T = 100 m K we obtain the ratio L=L '4 10^2 at eJ^y = 10 nA .

We have considered a simple example of the spin-orbit torque e ect produced by spin ux in a diusive 3D semiconductor lm. It would be interesting to study other systems, for example, a superlattice of remotely doped high mobility quantum wells in the ballistic regime (L is less than the elastic mean free path). In such a system energy dissipation within the semiconductor lm is reduced and, apparently, larger spin currents are allowable.

In sum mary, we propose a nanom echanical system where due to the strain-induced spin-orbit interaction the electron spin degree of freedom can couple to NMS mechanical motions. We have shown that this coupling is strong enough to induce the measurable torsion in NMS when the spin polarization ows through the suspended nanobeam. Besides a potential for other possible applications, such NMS can be employed as a sensitive detector of spin currents and spin polarizations. The basic structure can be further modiled to create devices for eventual use in spintronics as well as spin information processing.

This work was partly funded by the Taiwan National

Science Council; and RFBR grant No. 03-02-17452.

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